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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/047,455	01/15/2002	Edwin L. Piner	N00400/70013 RJP/RHW	1054	
23628 7	590 07/07/2006		EXAMINER		
WOLF GREENFIELD & SACKS, PC FEDERAL RESERVE PLAZA 600 ATLANTIC AVENUE		PC ,	HU, SHOUXIANG		
			ART UNIT	PAPER NUMBER	
BOSTON, MA 02210-2206			2811		

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)			
	10/047,455	PINER ET AL.			
Office Action Summary	Examiner	Art Unit	_		
	Shouxiang Hu	2811			
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	orrespondence address			
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DA - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. If NO period for reply is specified above, the maximum statutory period was Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 16(a). In no event, however, may a reply be tim iill apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONED	l. ely filed the mailing date of this communication. D (35 U.S.C. § 133).			
Status					
Responsive to communication(s) filed on This action is FINAL. 2b)⊠ This Since this application is in condition for allowar closed in accordance with the practice under E	action is non-final. ace except for formal matters, pro				
Disposition of Claims					
4) □ Claim(s) 1,12-16,19-22,30,39-43 and 45-47 is/4 4a) Of the above claim(s) 1,12-16,19-22,39-42 5) □ Claim(s) is/are allowed. 6) □ Claim(s) 30 and 43 is/are rejected. 7) □ Claim(s) is/are objected to. 8) □ Claim(s) are subject to restriction and/or	and 45-47 is/are withdrawn from	consideration.			
Application Papers	·				
 9) The specification is objected to by the Examine 10) The drawing(s) filed on is/are: a) access access access access and access acc	epted or b) objected to by the Edrawing(s) be held in abeyance. See non is required if the drawing(s) is obj	ected to. See 37 CFR 1.121(d).			
Priority under 35 U.S.C. § 119					
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 					
Attachment(s) Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal P 6) Other:	(PTO-413) tte atent Application (PTO-152)			

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DETAILED ACTION

Election/Restrictions

Claims 1, 12-16, 19-22, 39-42 and 45-47 are withdrawn from further consideration pursuant to 37 CFR 1.142(b), as being unreadable on the elected species.

The amended claim 1 recites the subject matters of an intrinsic gallium nitride material layer formed between the silicon substrate and the aluminum gallium nitride layer, which is only readable on the unelected species of Fig. 5, but unreadable on the elected species of Fig. 3.

Accordingly, claims 1, 12-16, 19-22, 30, 39-43 and 45-47 are pending in this application; and claims 30 and 43 remain active in this office action.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 30 and 43 are rejected under 35 U.S.C. 103(a) as being unpatentable over Ito (WO98/44569; also see US 6,583,442 for its English translation) in view of Bulsara (US 6,589,335).

Ito discloses a semiconductor structure (see US 6,583,442; Fig. 1, col. 3, lines 45-52, and col. 4, lines 1-10), comprising: a substrate layer (at least the bottom portion of the substrate layer similar to layer 101 in Fig. 1); a silicon germanium layer (at least the top portion layer of the substrate layer similar to layer 101 in Fig. 1); a gallium nitride material layer (similar to layer 102, 103, and/or 104); and, an intermediate layer (at least the layer 102; GaN, or a bottom portion of it).

Although Ito does not expressly disclose that the SiGe can be formed on a silicon substrate, one of ordinary skill in the art would readily recognize that a silicon substrate can be desirably and commonly used to form a SiGe layer thereon for improving the substrate's cost and/or quality, as evidenced in Bulsara (see the SiGe layer 104 on the silicon substrate 102 in Fig. 1A).

Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to incorporate the Si-substrate-based SiGe layer of Bulsara into the semiconductor structure of Ito, so that a structure with improvement in substrate quality and/or cost would be obtained.

Response to Arguments

Applicant's arguments filed on May 10, 2004 have been fully considered but they are not persuasive.

In response to applicant's arguments against the references individually, one cannot show nonobviousness by attacking references individually where the rejections are based on combinations of references. See *In re Keller*, 642 F.2d 413, 208

USPQ 871 (CCPA 1981); *In re Merck & Co.*, 800 F.2d 1091, 231 USPQ 375 (Fed. Cir. 1986). And, in response to applicant's argument that there is no suggestion to combine the references, the examiner recognizes that obviousness can only be established by combining or modifying the teachings of the prior art to produce the claimed invention where there is some teaching, suggestion, or motivation to do so found either in the references themselves or in the knowledge generally available to one of ordinary skill in the art. See *In re Fine*, 837 F.2d 1071, 5 USPQ2d 1596 (Fed. Cir. 1988)and *In re Jones*, 958 F.2d 347, 21 USPQ2d 1941 (Fed. Cir. 1992). In this case, Ito discloses the claimed invention, except the recited silicon substrate. Bulsara is cited to show that one of ordinary skill in the art would readily recognize that such a silicon substrate can be desirably and commonly used to form a SiGe layer thereon for improving the substrate's cost and/or quality. Therefore, it would be well within the ordinary skill in the art to incorporate the Si-substrate-based SiGe layer of Bulsara into the semiconductor structure of Ito, so as to make a structure with improved substrate quality and/or cost.

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Furthermore, Ito does not constitute any teaching away from the claimed invention, as the one of ordinary skill in the art would readily recognize that the LED structure shown in the cover page figure in Ito can naturally and readily emit light through the top transparent electrode, regardless what material the substrate is made of. Moreover, the SiGe substrate of Ito can be naturally regarded as an alloy of Si and Ge which can naturally cover an alloy composition with substantially low Ge, which will rend the substrate to be substantially similar to a silicon substrate in optical properties.

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Responses to applicant's other arguments have been incorporated into the

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Detailed Office action above.

Conclusion

Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Shouxiang Hu whose telephone number is 571-272-

1654. The examiner can normally be reached on Monday through Thursday, 7:30 AM

to 6:00 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Eddie C. Lee can be reached on 571-272-1732. The fax phone number for

the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the

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Should you have questions on access to the Private PAIR system, contact the

Electronic Business Center (EBC) at 866-217-9197 (toll-free).

SH

June 25, 2006

SHOUXIANG HU

PRIMARY EXAMINER